L	Hits	Search Text	DB	Time stamp
Number				_
1	129513	silicon near (layer film)	USPAT;	2004/03/16
1			US-PGPUB;	10:27
1			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
6	82047	remov\$3 near2 heat	USPAT;	2004/03/16
			US-PGPUB;	10:38
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
9	277075	(silicon near (oxide dioxide))	USPAT;	2004/03/16
		(sio."sub.2")	US-PGPUB;	10:38
			EPO; JPO;	
			DERWENT;	
12	22017	GOT /==12==================================	IBM_TDB	2004/03/16
12	22017	SOI (silicon near on near insulator)	USPAT;	10:40
		(silicon-on-insulator)	US-PGPUB; EPO; JPO;	10:40
			DERWENT;	i l
			IBM TDB	
13	246	(silicon near (layer film) ) and (remov\$3	USPAT;	2004/03/16
1 13	240	near2 heat) and ((silicon near (oxide	US-PGPUB;	10:40
		dioxide)) (sio."sub.2")) and (SOI	EPO; JPO;	10.10
		(silicon near on near insulator)	DERWENT;	
		(silicon-on-insulator)	IBM TDB	]